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INFORMATION DISCLOSURE

Atty Docket: Serial No.:

Serial No.: Applicant: Filing Date: Group: 62601 10/647,060 MEARS

AUGUST 22, 2003

U.S. PATENT DOCUMENTS							
Examiner Initials		Document Number	Date	Name	Class	Sub Class	Filing Date
TTN	AA	4,594,603	06/10/86	Holonyak, Jr.	357	16	01/24/85
l	AB	4,937,204	06/26/90	Ishibashi et al.	437	110	01/4/89
TTN	AC	4,969,031	11/06/90	Kobayashi et al.	357	63	02/3/83
	AD	5,05,887	10/08/91	Yamazaki	357	4	01/18/90
TTN	AE	5,216,262	06/1/93	Tsu	257	17	03/2/92
	AF	5,357,119	10/18/94	Wang et al.	257	18	02/19/93
	AG	5,684,817	11/04/97	Houdre et al.	372	45	05/1/96
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	Al	5,994,164	11/30/99	Fonash et al.	438	97	03/18/98
	AJ	6,058,127	05/2/00	Joannopoulos et al.	372	92	12/12/97
	AK	6,274,007	-08/14/01	Smirnov et al.	204	192	03/14/00
	AL	6,281,518	08/28/01	Sato	257	13	12/3/98
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	AN	6,344,271	02/05/02	Yadav et al.	428	402	03/23/99
	AO	6,472,685	10/29/02	Takagi	257	77	12/2/98
	AP	6,498,359	12/24/02	Schmidt et al.	257	190	05/18/01
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TW	AR	2003/ 0057416	03/27/03	Currie et al.	257	19	09/20/02
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TN/	AS	02/103767	12/27/02	wo	H01L	21/20	
TIN	AT	2,347,520	09/06/00	GB	G02B	5/18	
	AU						

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Sheet 2 of 2

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OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)					
TTW	AV	Xuan Luo et al.; "Chemical Design of Direct-Gap Light-Emitting Silicon", published July 25, 2002 by The American Physical Society; Vol. 89, Number 7			
TW	AW	R. Tsu; University of North Carolina at Charlotte, "Phenomena in Silicon Nanostructure Devices"; published 09/06/2000 © Springer-Verlag 2000			
TW	AX	P.D. Ye et al., "GaAs MOSFET with Oxide Gate Dielectric Grown by Atomic Layer Deposition"; © 2003 Agere Systems, March 2003			
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	AZ				
	ВА				

and the second	1/18/2004	

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Atty Docket: Serial No.: Applicant:

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62601 10/647,060 MEARS ET AL. AUGUST 22, 2003

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	AC	6,350,993	2/26/02	Chu et al.	257	19	
	AD	6,376,337	4/23/02	Wang et al.	438	478	
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	AL					<u></u>	
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TTW	AP	61220339A	9/30/86	Japan	H01L21	322	English Abstract
MI	AQ	61145820A	7/3/86	Japan	H01L21	20	English Abstract
TM	AR	99/63580	12/9/99	wo	H01L3	00	n/a

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